



GP 1725

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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Appln. Of: TANABE et al.
Serial No.: 09/612,551
Filed: July 7, 2000
For: SEMICONDUCTOR THIN FILM FORMING SYSTEM
Group: 1725
Examiner: GEOFFREY S. EVANS DOCKET: NEC WNZ-2212

Assistant Commissioner of Patents and Trademarks
Washington, D.C. 20231

AMENDMENT C

Dear Sir:

The following Amendment is being filed in response to the Official Action mailed
June 21, 2002.

Please amend the Application as follows:

IN THE CLAIMS:

Please add new claims 17-22 reading as follows:

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- C1
- SVB
D2
- 17. A system according to claim 1, wherein said projected light comprises a laser source.
18. A system according to claim 17, wherein said laser source comprises an excimer laser.
19. A system according to claim 17, wherein said mechanism for uniformizing the light comprises a homogenizer, a mask and a projection lens through which said light is applied.
20. A system according to claim 19, wherein said mask includes a slit for throttling light passed through the homogenizer into a rectangular beam.

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